



FEI Opens China NanoPort

New Facility to Focus on Collaboration with Researchers and Developers

HILLSBORO, Ore., Jan 18, 2008 (BUSINESS WIRE) -- FEI Company (Nasdaq: FEIC) today opened a NanoPort in Shanghai, China. FEI NanoPorts are centers of technical and applications excellence where FEI customers and partners can collaborate with FEI specialists on the ongoing development of new ideas and innovative solutions for advancing nanoscale technology. The new facility is the fourth such location joining those already in operation in North America, Europe and Japan.

FEI NanoPorts are located in key centers of technology excellence where there is a critical number of customers and partners to encourage the advancement of nanoscale development. Shanghai was selected as a location for the company's fourth Nanoport because it is a vibrant and growing technology center in China with global recognition. As China continues to be a world leader in nanotechnology investment and development, FEI's NanoPort will serve as a local resource for supporting scientific breakthroughs in China.

"China is playing a significant role in the global focus on developing new, nano-enabled technologies that have the potential to address many of the major challenges facing mankind including cleaner, renewable energy, disease, food sources, terrorism and crime," commented Benjamin Loh, executive vice president of worldwide sales and service for FEI, while addressing Chinese customers, dignitaries and journalists attending opening events for the NanoPort. "Our customers in China work in electronics, life science and a wide spectrum of advanced academic and industrial research. With a NanoPort in China, we are better able to partner with them and contribute to their ongoing success and the technology advances coming out of China."

The skilled expertise of FEI's application and product experts and the equipment housed in FEI NanoPorts also provide critical resources for the cooperative development of new technologies and advances in microscopy with leading government and academic institutions such as the U.S. Department of Energy TEAM Project (achieving 0.5 Angstrom resolution) and the recently announced program with the Netherlands FOM Foundation for the development of tools for single-atom imaging and processing of material structures, among others.

The China NanoPort will house FEI solutions that provide ultra-high resolution and applications for materials inspection and characterization, including 3D characterization prototyping and analysis on the nanoscale. It is located at 690 Bibo Road, Building 8, Pudong, Shanghai. The local telephone number is + 86 (0)21 5027 8805 5606.

About FEI Company

FEI (Nasdaq: FEIC) is a world leader in pioneering industry-leading technologies and applications that deliver imaging solutions for 3D characterization, analysis and modification/prototyping with resolutions down to the sub-Angstrom level. Our customers, working in advanced research and manufacturing, are supported by field-experienced applications specialists and open access to FEI's prestigious global user network so they can succeed in accelerating nanoscale discovery and contribute to better living through new product commercialization. FEI's NanoPorts in North America, Europe and Asia provide centers of technical excellence where our world-class community of customers and specialists collaborate on the ongoing development of new ideas and innovative solutions. FEI has sales and service operations in more than 50 countries around the world. More information can be found at: www.fei.com.

SOURCE: FEI Company

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